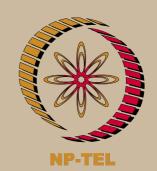
Advanced Characterization Techniques - Video course

COURSE OUTLINE

- 1. Advanced Diffraction Techniques: SAXS, SANS, LEED, RHEED, EXAFS.
- 2. A d v a n c e d Surface Characterization Techniques: XPS,AES, SIMS
- 3. A d v a n c e d Microscopic Techniques: TEM: HR,HAADF,STEM,In-situ; EBSD,AFM,STM, Laser Confocal Microscopy
- 4. Advanced Spectroscopic Techniques: Vis,UV,FTIR, Raman, STEM-EELS

COURSE DETAIL

SI. No	Торіс	Hours
1.	Introduction to the course: Relevance of advanced characterization to materials development, scientific understanding of phenomena in materials technology	1
2.	Advanced Diffraction Techniques: Introduction; X-Ray, their production &properties Review of basic diffraction theory;	3
3.	 Various SAXS techniques and its applications in characterizing material SAXS GISAXS 	4
	LEED and RHEED	



NPTEL

http://nptel.ac.in

Metallurgy and Material Science

Pre-requisites:

Basic knowledge on basic materials characterization techniques is the primary requirement for this course

Coordinators:

Dr. Krishanu Biswas

Department of Materials and Metallurgical EngineeringIIT Kanpur

Prof.N.P.Gurao

Department of MSEIIT Kanpur

4. Properties of neutron radiation; neutron sources; • Small angle neutron scattering; Examples 5. • Advanced Surface Characterization Techniques: XPS, AES & SIMS; • Importance of surface characterization techniques; • Physical principles of XPS, Photoelectric effects; 6. Instrumentation, XPS patterns; Spin orbital Splitting; Quantitative analysis, Chemical effect, Chemical shift, XPS imaging Auger electron generation; Principle, Chemical effect, Quantitative analysis, Depth profiling, Applications 7. Static and Dynamic Secondary Ion Mass, Common modes of analysis, Depth Profiling, quantitative and Qualitative analysis 8. Comparison surface analysis techniques 1. Advanced Spectroscopic Techniques: Introduction; Electromagnetic spectroscopy; UV-Visible Spectroscopy; Photo-luminescence spectroscopy; Infrared spectroscopy;
Techniques: XPS, AES & SIMS; Importance of surface characterization techniques; Physical principles of XPS, Photoelectric effects; Instrumentation, XPS patterns; Spin orbital Splitting; Quantitative analysis, Chemical effect, Chemical shift, XPS imaging Auger electron generation; Principle, Chemical effect, Quantitative analysis, Depth profiling, Applications 7. Static and Dynamic Secondary Ion Mass, Common modes of analysis, Depth Profiling, quantitative and Qualitative analysis 8. Comparison surface analysis techniques 1 9. Advanced Spectroscopic Techniques: Introduction; Electromagnetic spectroscopy; UV-Visible Spectroscopy; Photo-luminescence spectroscopy; Infra-
Splitting; Quantitative analysis, Chemical effect, Chemical shift, XPS imaging Auger electron generation; Principle, Chemical effect, Quantitative analysis, Depth profiling, Applications 7. Static and Dynamic Secondary Ion Mass, Common modes of analysis, Depth Profiling, quantitative and Qualitative analysis 8. Comparison surface analysis techniques 1 9. Advanced Spectroscopic Techniques: Introduction; Electromagnetic spectroscopy; UV-Visible Spectroscopy; Photo-luminescence spectroscopy; Infra-
Common modes of analysis, Depth Profiling, quantitative and Qualitative analysis 8. Comparison surface analysis techniques 1 9. Advanced Spectroscopic Techniques: Introduction; Electromagnetic spectroscopy; UV-Visible Spectroscopy; Photo-luminescence spectroscopy; Infra-
9. Advanced Spectroscopic Techniques: 7 Introduction; Electromagnetic spectroscopy; UV-Visible Spectroscopy; Photo-luminescence spectroscopy; Infra-
Introduction; Electromagnetic spectroscopy; UV-Visible Spectroscopy; Photo-luminescence spectroscopy; Infra-
10. Raman; STEM; EELS 3
11. Advanced Microscopic 1 Techniques:Introduction; Electronmaterials interactions;

12.	TEM: HR, HAADF, STEM, In-situ TEM;	4
13.	SEM, EBSD, In-situ SEM	2
14.	AFM, STM	2
15.	Laser Confocal Microscopy	1

References:

- 1. Materials Characterization Techniques Sam Zhang, Lin Li, Ashok Kumar;CRC press, (2008)
- 2. Transmission Electron Microscopy; D.B. Williams and C.B. Carter, Plenum Press (2004)
- 3. Modern ESCAThe Principles and Practice of X-Ray Photoelectron Spectroscopy, Terry L.Barr, CRC press, (1994)
- 4. Scanning Electron Microscopy and X-ray Microanalysis by Joseph Goldstein, Dale E. Newbury, David C. Joy, and Charles E.; Springer Science (2003)
- Advanced Techniques for Materials Characterization, Materials Science Foundations (monograph series) A. K. Tyagi, Mainak Roy, S. K. Kulshreshtha and S. Banerjee; Volumes 49 – 51 (2009)
- 6. Encyclopedia of Materials Characterisation Editors: c.r. Brundle, C.A. Evens, Jr, S. Wilson, Butterworth-Heinmann, Boston (1992)

A joint venture by IISc and IITs, funded by MHRD, Govt of India

http://nptel.ac.in